



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Takahiro KISHIOKA et al.

Group Art Unit: 1752

Application No.: 10/520,461

Examiner: A. WALKER

Filed: January 7, 2005

Docket No.: 122364

For: COMPOSITION FOR FORMING ANTI-REFLECTIVE COATING

REQUEST FOR RECONSIDERATION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In further reply to the April 6, 2007 Office Action, and in conjunction with the Request for Continued Examination filed herewith, reconsideration of the rejection is respectfully requested in light of the following remarks.

Claims 1, 4-8, 10 and 11 are pending in this application. By the Office Action, claims 1, 4-8, 10 and 11 are rejected under 35 U.S.C. §103(a).

I. Rejections under 35 U.S.C. §103(a)

The Office Action rejects claims 1, 4-8, 10 and 11 under 35 U.S.C. §103(a) over Kang in view of Mizutani or either Bonk reference. The Office Action asserts that Kang discloses each claimed feature, except for the instantly claimed compound, which is allegedly taught by Mizutani or either Bonk. Applicants respectfully traverse the rejection.

A. The Claimed Invention

Independent claim 1 is directed to a composition for forming anti-reflective coating used for lithography process for manufacturing a semiconductor device characterized by